



(86) Date de dépôt PCT/PCT Filing Date: 2000/12/04
 (87) Date publication PCT/PCT Publication Date: 2001/06/28
 (45) Date de délivrance/Issue Date: 2006/10/17
 (85) Entrée phase nationale/National Entry: 2002/06/18
 (86) N° demande PCT/PCT Application No.: US 2000/032878
 (87) N° publication PCT/PCT Publication No.: 2001/046495
 (30) Priorité/Priority: 1999/12/21 (US09/469,259)

(51) Cl.Int./Int.Cl. *C23C 22/83* (2006.01),
B23K 35/22 (2006.01), *B05D 7/00* (2006.01),
C08G 59/18 (2006.01), *C09D 5/08* (2006.01),
C23C 22/34 (2006.01), *C23C 22/48* (2006.01),
C23C 22/68 (2006.01)

(72) Inventeurs/Inventors:
 HAUSER, BRIAN T., US;
 GRAY, RALPH C., US;
 NUGENT, RICHARD M., JR., US;
 WHITE, MICHAEL L., US

(73) Propriétaire/Owner:
 PPG INDUSTRIES OHIO, INC., US

(74) Agent: BORDEN LADNER GERVAIS LLP

(54) Titre : SUBSTRATS METALLIQUES REVETUS ET PROCEDES DE PREPARATION ET D'INHIBITION DE LA
 CORROSION ASSOCIES
 (54) Title: COATED METAL SUBSTRATES AND METHODS FOR PREPARING AND INHIBITING CORROSION OF THE
 SAME

(57) **Abrégé/Abstract:**

The present invention provides a metal substrate coated with a first pretreatment composition including a transition element-containing material having one or more Group IVB elements. Group IVB elements, lanthanide series elements or mixtures thereof; and a second pretreatment composition including a reaction product of at least one epoxy-functional material or derivative thereof and at least phosphorus-containing, material, amine-containing material and/or sulfur-containing material deposited upon the first pretreatment composition. If desired, the first and second pretreatment compositions can be combined into a single pretreatment.

(12) INTERNATIONAL APPLICATION PUBLISHED UNDER THE PATENT COOPERATION TREATY (PCT)

(19) World Intellectual Property Organization
International Bureau



(43) International Publication Date
28 June 2001 (28.06.2001)

PCT

(10) International Publication Number
WO 01/46495 A3

- (51) International Patent Classification⁷: C23C 22/83, 22/34, 22/68
- (21) International Application Number: PCT/US00/32878
- (22) International Filing Date: 4 December 2000 (04.12.2000)
- (25) Filing Language: English
- (26) Publication Language: English
- (30) Priority Data:
09/469,259 21 December 1999 (21.12.1999) US
- (71) Applicant: PPG INDUSTRIES OHIO, INC. [US/US];
3800 West 143rd Street, Cleveland, OH 44111 (US).
- (72) Inventors: HAUSER, Brian, T.: 4014 Chelstead Way, Murrysville, PA 15668 (US). GRAY, Ralph, C.: 137 West Cruikshank Road, Butler, PA 16001 (US). NUGENT, Richard, M., Jr.: 2949 Elsiton Lane, Allison Park, PA 15101 (US). WHITE, Michael, L.: 494 Woodland Road, Pittsburgh, PA 15237 (US).
- (74) Agents: ALTMAN, Deborah, M. et al.: PPG Industries, Inc., One PPG Place, Pittsburgh, PA 15272 (US).
- (81) Designated States (*national*): AE, AG, AL, AM, AT, AU, AZ, BA, BB, BG, BR, BY, BZ, CA, CH, CN, CR, CU, CZ, DE, DK, DM, DZ, EE, ES, FI, GB, GD, GE, GH, GM, HR, HU, ID, IL, IN, IS, JP, KE, KG, KP, KR, KZ, LC, LK, LR, LS, LT, LU, LV, MA, MD, MG, MK, MN, MW, MX, MZ, NO, NZ, PL, PT, RO, RU, SD, SE, SG, SI, SK, SL, TJ, TM, TR, TT, TZ, UA, UG, UZ, VN, YU, ZA, ZW.
- (84) Designated States (*regional*): ARIPO patent (GH, GM, KE, LS, MW, MZ, SD, SL, SZ, TZ, UG, ZW), Eurasian patent (AM, AZ, BY, KG, KZ, MD, RU, TJ, TM), European patent (AT, BE, CH, CY, DE, DK, ES, FI, FR, GB, GR, IE, IT, LU, MC, NL, PT, SE, TR), OAPI patent (BF, BJ, CF, CG, CI, CM, GA, GN, GW, ML, MR, NE, SN, TD, TG).
- Published:**
— with international search report
- (88) Date of publication of the international search report:
24 January 2002
- For two-letter codes and other abbreviations, refer to the "Guidance Notes on Codes and Abbreviations" appearing at the beginning of each regular issue of the PCT Gazette.*

(54) Title: COATED METAL SUBSTRATES AND METHODS FOR PREPARING AND INHIBITING CORROSION OF THE SAME

(57) Abstract: The present invention provides a metal substrate coated with a first pretreatment composition including a transition element-containing material having one or more Group IIIB elements, Group IVB elements, lanthanide series elements or mixtures thereof; and a second pretreatment composition including a reaction product of at least one epoxy-functional material or derivative thereof and at least phosphorus-containing material, amine-containing material and/or sulfur-containing material deposited upon the first pretreatment composition. If desired, the first and second pretreatment compositions can be combined into a single pretreatment.

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**COATED METAL SUBSTRATES AND METHODS
FOR PREPARING AND INHIBITING CORROSION OF THE SAME**

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Field of the Invention

This invention relates generally to corrosion-resistant coated metal substrates and, more particularly, to ferrous and non-ferrous metal substrates having environmentally friendly chrome-free and nickel-free coatings thereon which inhibit corrosion of the metal substrate.

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Background of the Invention

Pretreating metal substrates with a phosphate conversion coating and rinsing with a chrome-containing sealer is well known for promoting corrosion resistance and improving the adhesion of subsequently applied decorative and protective coatings. Cationic electrodeposition compositions are typically applied over phosphated steel substrates to further improve corrosion resistance. While the combination of phosphate conversion coating and

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electrodeposited coating provides superior corrosion resistance, heavy metals typically used in such coatings can provide environmental disposal concerns. For example, phosphate conversion coating compositions typically contain heavy metals such as nickel and post-rinses contain chrome, while cationic
5 electrodeposition compositions typically are formulated with lead as a pigment or soluble lead salt. Also, conventional phosphating processes can require eleven to twenty-five stages that occupy a large amount of physical space in a plant and require significant capital investment. Another drawback of
conventional phosphating processes is difficulty in coating mixed-metal objects
10 including aluminum.

Nickel-free phosphate coating compositions and chrome-free rinsing compositions having comparable corrosion resistance to nickel- and chrome-containing compositions are highly desirable. Rinsing compositions utilizing metal ions other than chromium are disclosed, for example, in U. S. Patents
15 3,966,502 and 4,132,572. U. S. Patent 3,966,502 discloses treatment of phosphated metals with zirconium-containing rinse solutions. U.S. Patents 3,912,548, 5,209,788, and 5,653,823 disclose other rinse compositions containing combinations of Group IVB metal ions with polymeric materials that have been used over phosphated substrates. However, many post-rinse
20 compositions are suitable for use over a limited number of substrates or over substrates that must be phosphated first.

It would be desirable to provide a simplified pretreatment process free of heavy metals for coating metal substrates, including mixed metal substrates such as are commonly found on today's automobile bodies. Such a
25 pretreatment process, when combined with a lead-free electrodeposition process, would provide an environmentally friendly alternative for providing corrosion resistance to metal substrates.

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Summary of the Invention

The present invention provides a coated metal substrate comprising: (a) a metal substrate; (b) a first pretreatment composition deposited upon at least a portion of the substrate, the first pretreatment composition comprising a
5 transition element-containing material which comprises a transition element selected from the group consisting of Group IIIB elements, Group IVB elements, lanthanide series elements and mixtures thereof; and (c) a second pretreatment composition comprising a reaction product of at least one epoxy-functional material or derivative thereof and at least one material selected from
10 the group consisting of phosphorus-containing materials, amine-containing materials, sulfur-containing materials and mixtures thereof deposited upon at least a portion of the first pretreatment composition.

In another aspect of the present invention, a weldable, coated metal substrate is provided which comprises (a) a metal substrate; (b) a first
15 pretreatment composition comprising a transition element-containing material which comprises a transition element selected from the group consisting of Group IIIB elements, Group IVB elements, lanthanide series elements and mixtures thereof deposited upon at least a portion of the substrate; (c) a second pretreatment composition comprising a reaction product of at least one
20 epoxy functional material or derivative thereof and at least one material selected from the group consisting of phosphorus-containing materials, amine-containing materials, sulfur-containing materials and mixtures thereof deposited upon at least a portion of the first pretreatment composition; and (d)
25 a weldable composition comprising an electroconductive pigment and a binder deposited upon at least a portion of the second pretreatment composition.

In another aspect of the present invention, a coated metal substrate is provided which comprises: (a) a metal substrate; (b) a first pretreatment composition comprising a transition element-containing material which comprises a transition element selected from the group consisting of Group IIIB

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elements, Group IVB elements, lanthanide series elements and mixtures thereof deposited upon at least a portion of the substrate; and (c) a second pretreatment composition comprising an ester of a phosphorus-containing material deposited upon at least a portion of the first pretreatment composition.

5 In another aspect of the present invention, a method for preparing a coated metal substrate is provided which comprises the steps of: (a) treating a surface of a metal substrate with a first pretreatment composition comprising a transition element-containing material which comprises a transition element selected from the group consisting of Group IIIB elements, Group IVB
10 elements, lanthanide series elements and mixtures thereof; and (b) applying a second pretreatment composition comprising a reaction product of at least one epoxy functional material or derivative thereof and at least one material selected from the group consisting of phosphorus-containing materials, amine-containing materials, sulfur-containing materials and mixtures thereof over at
15 least a portion of the first pretreatment composition to form a substrate having a pretreated surface.

In another aspect of the present invention, a method for inhibiting corrosion of a metal substrate is provided which comprises: (a) treating a surface of a metal substrate with a first pretreatment composition comprising a
20 transition element-containing material which comprises a transition element selected from the group consisting of Group IIIB elements, Group IVB elements, lanthanide series elements and mixtures thereof; (b) applying a second pretreatment composition comprising a reaction product of at least one epoxy functional material or derivative thereof and at least one material
25 selected from the group consisting of phosphorus-containing materials, amine-containing materials, sulfur-containing materials and mixtures thereof over at least a portion of the first pretreatment composition to form a substrate having a pretreated surface; and (c) applying a weldable coating to the pretreated

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surface to form a corrosion-resistant coated metal substrate, the weldable coating comprising an electroconductive pigment and a binder.

In another aspect of the present invention, a coated metal substrate is provide which comprises: (a) a metal substrate; and (b) a pretreatment composition deposited upon at least a portion of the substrate, the pretreatment composition comprising (1) a transition element-containing material which comprises a transition element selected from the group consisting of Group IIIB elements, Group IVB elements, lanthanide series elements and mixtures thereof; and (2) a reaction product of at least one epoxy-functional material or derivative thereof and at least one material selected from the group consisting of phosphorus-containing materials, amine-containing materials, sulfur-containing materials and mixtures thereof deposited upon at least a portion of the first pretreatment composition.

In another aspect of the present invention, a method for preparing a coated metal substrate is provided which comprises the step of treating a surface of a metal substrate with a pretreatment composition comprising (1) a transition element-containing material which comprises a transition element selected from the group consisting of Group IIIB elements, Group IVB elements, lanthanide series elements and mixtures thereof; and (2) a reaction product of at least one epoxy functional material or derivative thereof and at least one material selected from the group consisting of phosphorus-containing materials, amine-containing materials, sulfur-containing materials and mixtures thereof over at least a portion of the first pretreatment composition to form a substrate having a pretreated surface.

25

Also, as used herein, the term "polymer" is meant to refer to oligomers, homopolymers and copolymers.

Detailed Description of the Preferred Embodiments

The metal substrates used in the practice of the present invention include ferrous metals, non-ferrous metals and combinations thereof. Suitable ferrous metals include iron, steel, and alloys thereof. Non-limiting examples of useful steel materials include cold rolled steel, hot galvanized (zinc coated) steel, electrogalvanized steel, stainless steel, pickled steel, zinc-iron alloy such as GALVANNEAL*, GALVALUME* and Galfan* zinc-aluminum alloys coated over steel, and combinations thereof. Useful non-ferrous metals include aluminum, zinc, magnesium and alloys thereof. Combinations or composites of ferrous and non-ferrous metals can also be used. The shape of the metal substrate can be in the form of a sheet, plate, bar, rod or any shape desired.

Before depositing the coating compositions of the present invention upon the surface of the metal substrate, it is preferred to remove dirt or foreign matter from the metal surface by thoroughly cleaning and degreasing the surface. The surface of the metal substrate can be cleaned by physical or chemical means, such as mechanically abrading the surface or cleaning/degreasing with commercially available alkaline or acidic cleaning agents which are well known to those skilled in the art, such as sodium metasilicate and sodium hydroxide. Non-limiting examples of suitable alkaline cleaning agents include CHEMKLEEN* 163 and CHEMKLEEN* 177 phosphate cleaners that are commercially available from PPG Industries, Inc. of Pittsburgh, Pennsylvania.

Following the cleaning step, the surface of the metal substrate is usually rinsed with water, preferably deionized water, in order to remove any residue. Optionally, the metal surface can be rinsed with an aqueous acidic solution after cleaning with the alkaline cleaner and before contact with the passivating compositions. Examples of rinse solutions include mild or strong acidic cleaners such as the dilute nitric acid solutions commercially available and conventionally used in metal pretreatment processes. The metal substrate can

* Trade-mark

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be air dried using an air knife, by flashing off the water by brief exposure of the substrate to a high temperature or by passing the substrate between squeegee rolls.

5 Optionally, a phosphate-based conversion coating can be applied to the metal substrate. Suitable phosphate conversion coating compositions include those known in the art, such as zinc phosphate, optionally modified with nickel, iron, manganese, calcium, magnesium or cobalt. Useful phosphating compositions are described in U.S. Patents 4,941,930; 5,238,506, and 5,653,790.

10 Following the optional acid rinsing and phosphating steps, the metal substrate is contacted with a first pretreatment or passivating composition that improves the corrosion resistance of the metal substrate compared to its corrosion resistance without such a treatment. The first pretreatment composition comprises one or more transition element-containing materials
15 which comprise one or more transition elements selected from the group consisting of Group IIIB elements, Group IVB elements, lanthanide series elements and mixtures thereof. The Group IIIB elements, Group IVB elements and lanthanide series elements referred to herein are those elements included in such groups in the CAS Periodic Table of the Elements as shown, for
20 example, in the Handbook of Chemistry and Physics, (56th Ed. 1975) inside cover.

Preferred Group IIIB elements include yttrium, lanthanum and mixtures thereof. Preferred lanthanide series elements include cerium, praseodymium, neodymium, samarium, europium, dysprosium and mixtures thereof. Preferred
25 Group IVB elements include zirconium, titanium, hafnium and mixtures thereof. Mixtures of Group IIIB, Group IVB and/or lanthanide series elements can be used. Zirconium- and titanium-containing materials are preferred.

Non-limiting examples of suitable Group IIIB transition element-containing materials include nitrates, acetates, sulfamates, lactates, glycolates,

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formates and dimethylol propionates of yttrium and/or lanthanum, where such compounds exist. Non-limiting examples of suitable lanthanide series transition element-containing materials include nitrates, acetates, sulfamates, lactates, glycolates, formates and dimethylol propionates of cerium, praseodymium, neodymium, samarium, europium and/or dysprosium, where such compounds exist.

Non-limiting examples of suitable zirconium-containing materials include fluorozirconic acids, such as hexafluorozirconic acid, alkali metal and ammonium salts thereof such as potassium hexafluorozirconate, alkali or amine salts of zirconium hexafluoride; ammonium zirconium carbonate; zirconyl nitrate; zirconium carboxylates such as zirconium acetate, zirconium oxalate, ammonium zirconium glycolate, ammonium zirconium lactate, ammonium zirconium citrate, and mixtures thereof. Hexafluorozirconic acid is preferred. Non-limiting examples of suitable titanium-containing materials include fluorotitanic acid, alkali salts of hexafluorotitanate, amine salts of hexafluorotitanate and mixtures thereof.

The first pretreatment composition typically is dispersed or dissolved in a carrier medium, such as an aqueous medium. Preferably, the transition element-containing materials are in the form of metal salts or acids that are water soluble. The transition element-containing materials can be present in the carrier medium in an amount of up to 10,000 ppm, preferably 10 to 2000 ppm metal, and more preferably 100 to 1000 ppm metal based on total weight of the composition. The pH of the medium is usually 2.0 to 7.0, preferably 3 to 5. The pH of the medium may be adjusted using mineral acids such as hydrofluoric acid, fluoroboric acid, phosphoric acid, and the like, including mixtures thereof; organic acids such as lactic acid, acetic acid, citric acid, sulfamic acid, or mixtures thereof; and water soluble or water dispersible bases such as sodium hydroxide, ammonium hydroxide, ammonia, or amines such as triethylamine, methylethanol amine, or mixtures thereof.

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Additionally, the first pretreatment composition can comprise one or more film-forming materials or resins. Suitable resins include reaction products of one or more alkanolamines and an epoxy-functional material containing at least two epoxy groups, such as those disclosed in U.S. Patent No. 5,653,823.

5 Preferably, such resins contain beta hydroxy ester, imide, or sulfide functionality, incorporated by using dimethylolpropionic acid, phthalimide, or mercaptoglycerine as an additional reactant in the preparation of the resin. Alternatively, the reaction product is that of the diglycidyl ether of Bisphenol A (commercially available from Shell Chemical Company as EPON 880 or EPON

10 828 LC), dimethylol propionic acid, and diethanolamine in a 0.6 to 5.0:0.05 to 5.5:1 mole ratio. Other suitable resins include water soluble and water dispersible polyacrylic acids as disclosed in U.S. Patent Nos. 3,912,548 and 5,328,525; phenol-formaldehyde resins as described in U.S. Patent No. 5,662,746; water soluble polyamides such as those disclosed in WO 95/33869;

15 copolymers of maleic or acrylic acid with allyl ether as described in Canadian patent application no. 2,087,352; and water soluble and dispersible resins including epoxy resins, aminoplasts, phenol-formaldehyde resins, tannins, and polyvinyl phenols as discussed in U.S. Patent No. 5,449,415.

In this embodiment of the invention, the film forming resin is present in

20 the first pretreatment coating composition in an amount of 0.005% to 30% based on the total weight of the first pretreatment composition, and the transition element-containing material is present in an amount of 10 to 10,000, preferably 100 to 2000 ppm metal based on total weight of the first pretreatment composition. The weight ratio of the resin to transition element-

25 containing materials is from 2.0 to 10.0, preferably 3.0 to 5.0, based on metal.

The pretreatment coating composition can further comprise one or more crosslinking materials for crosslinking crosslinkable components of the composition, such as the film-forming resin. Useful crosslinking materials include blocked or unblocked polyisocyanates, aminoplasts, polyacids,

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polyanhydrides and mixtures thereof such as are well known to those skilled in the art. The amount of the crosslinking material in the pretreatment coating composition can range from 0.05 to 60 weight percent on a basis of total resin solids weight of the pretreatment coating composition.

5 The pretreatment coating composition can further comprise surfactants that function as aids to improve wetting of the substrate. Generally, the surfactant materials are present in an amount of less than 2 weight percent on a basis of total weight of the pretreatment coating composition. Other optional materials in the carrier medium include surfactants that function as defoamers
10 or substrate wetting agents.

 Preferably, the pretreatment coating composition is essentially free of chromium-containing materials, i.e., contains less than 2 weight percent of chromium-containing materials (expressed as CrO_3), and more preferably less than 0.05 weight percent of chromium-containing materials. Examples of such
15 chromium-containing materials include chromic acid, chromium trioxide, chromic acid anhydride, and chromate and dichromate salts of ammonium, sodium, potassium, calcium, barium, zinc and strontium. Most preferably, the pretreatment coating composition is free of chromium-containing materials.

 The first pretreatment composition is deposited upon at least a portion of
20 an exposed surface of the metal substrate. Preferably, the entire exposed surface of the metal substrate is coated with the first pretreatment composition.

 The first pretreatment composition can be applied to the metal substrate by known application techniques, such as dipping or immersion, which is preferred, spraying, intermittent spraying, dipping followed by spraying,
25 spraying followed by dipping, brushing, or by roll-coating. Typically, the solution or dispersion when applied to the metal substrate is at a temperature ranging from 60°F to 150°F (15°C to 65°C). The contact time is generally between less than one second and five minutes, preferably 30 seconds to 2 minutes.

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Continuous coating processes are typically used in the coil coating industry and also for mill application. The first pretreatment coating composition can be applied by any of these conventional processes. For example, in the coil industry, the substrate is cleaned and rinsed and then usually contacted with the pretreatment coating composition by roll coating with a chemical coater. The treated strip is then dried by heating and painted and baked by conventional coil coating processes.

Optionally, the pretreatment composition can be applied in a mill by immersion, spray or roll coating the freshly manufactured metal strip. Excess pretreatment composition is typically removed by wringer rolls. After the first pretreatment composition has been applied to the metal surface, the metal can be rinsed with deionized water and dried at room temperature or at elevated temperatures to remove excess moisture from the treated substrate surface and cure any curable coating components to form the first pretreatment coating. Alternately, the treated substrate can be heated at 65°C to 250°C for 2 seconds to 1 minute to produce a coated substrate having a dried or cured residue of the first pretreatment coating composition thereon. If the substrate is already heated from the hot melt production process, no post application heating of the treated substrate is required to facilitate drying. The temperature and time for drying the coating will depend upon such variables as the percentage of solids in the coating, components of the coating composition and type of substrate.

The film coverage of the residue of the first pretreatment composition generally ranges from 0.1 to 500 milligrams per square meter (mg/m^2), and is preferably 0.1 to 1 mg/m^2 . The thickness of the first pretreatment composition can vary, but is generally less than 1 micrometer, preferably ranges from 1 to 500 nanometers, and more preferably is 10 to 300 nanometers.

In the present invention, a second pretreatment composition is deposited upon at least a portion of the first pretreatment composition. The

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second pretreatment composition comprises a reaction product of one or more epoxy-functional materials or derivatives thereof and one or more materials selected from phosphorus-containing materials, amine-containing materials, sulfur-containing materials and mixtures thereof.

- 5 Useful epoxy-functional materials contain at least one epoxy or oxirane group in the molecule, such as monoglycidyl ethers of a monohydric phenol or alcohol or di- or polyglycidyl ethers of polyhydric alcohols. Preferably, the epoxy-functional material contains at least two epoxy groups per molecule and has aromatic or cycloaliphatic functionality to improve adhesion to the metal
- 10 substrate. Further, it is preferred that the epoxy-functional materials be relatively more hydrophobic than hydrophilic in nature.

- Examples of suitable monoglycidyl ethers of a monohydric phenol or alcohol include phenyl glycidyl ether and butyl glycidyl ether. Useful polyglycidyl ethers of polyhydric alcohols can be formed by reacting
- 15 epihalohydrins with polyhydric alcohols, such as dihydric alcohols, in the presence of an alkali condensation and dehydrohalogenation catalyst such as sodium hydroxide or potassium hydroxide. Useful epihalohydrins include epibromohydrin, dichlorohydrin and epichlorohydrin (preferred). Suitable polyhydric alcohols can be aromatic, aliphatic or cycloaliphatic.

- 20 Non-limiting examples of suitable aromatic polyhydric alcohols include phenols that are preferably at least dihydric phenols. Non-limiting examples of aromatic polyhydric alcohols useful in the present invention include dihydroxybenzenes, for example resorcinol, pyrocatechol and hydroquinone; bis(4-hydroxyphenyl)-1,1-isobutane; 4,4-dihydroxybenzophenone; bis(4-
- 25 hydroxyphenyl)-1,1-ethane; bis(2-hydroxyphenyl)methane; 1,5-hydroxynaphthalene; 4-isopropylidene bis(2,6-dibromophenol); 1,1,2,2-tetra(p-hydroxy phenyl)-ethane; 1,1,3-tris(p-hydroxy phenyl)-propane; novolac resins; bisphenol F; long-chain bisphenols; and 2,2-bis(4-hydroxyphenyl)propane, i.e., bisphenol A (preferred).

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Non-limiting examples of aliphatic polyhydric alcohols include glycols such as ethylene glycol, diethylene glycol, triethylene glycol, 1,2-propylene glycol, 1,4-butylene glycol, 2,3-butylene glycol, pentamethylene glycol, polyoxyalkylene glycol; polyols such as sorbitol, glycerol, 1,2,6-hexanetriol, erythritol and trimethylolpropane; and mixtures thereof. An example of a suitable cycloaliphatic alcohol is cyclohexanedimethanol.

Suitable epoxy-functional materials have an epoxy equivalent weight ranging from 100 to 4000, and preferably 100 to 500, as measured by titration with perchloric acid using methyl violet as an indicator. Useful epoxy-functional materials are disclosed in U.S. Patent Nos. 5,294,265; 5,306,526 and 5,653,823.

Examples of suitable commercially available epoxy-functional materials are EPON® 828 LC (880), 1001, 1002, 1004, 1007, 1009, 826 and 828 epoxy resins, which are epoxy functional polyglycidyl ethers of bisphenol A prepared from bisphenol-A and epichlorohydrin and are commercially available from Shell Chemical Company. EPON® 828 epoxy resin has a number average molecular weight of 400 and an epoxy equivalent weight of 185-192. EPON® 826 epoxy resin has an epoxy equivalent weight of 178-186.

Other useful epoxy-functional materials include epoxy-functional acrylic polymers, glycidyl esters of carboxylic acids and mixtures thereof.

Useful derivatives of epoxy-functional materials include the reaction products of one or more epoxy-functional materials such as are discussed above with one or more substituted aldehydes or ketones or mixtures thereof. Suitable hydroxy-substituted aldehydes and ketones include 4-hydroxybenzaldehyde, 3-hydroxybenzaldehyde, 2-hydroxybenzaldehyde (salicylaldehyde), vanillin, syringaldehyde, 2'-hydroxyacetophenone, 3'-hydroxyacetophenone, 4'-hydroxyacetophenone, 4'-hydroxy-2'-methylacetophenone, 4'-hydroxy-4'-methylacetophenone and 2,4-dihydroxybenzophenone. Useful amino substituted aldehydes and ketones

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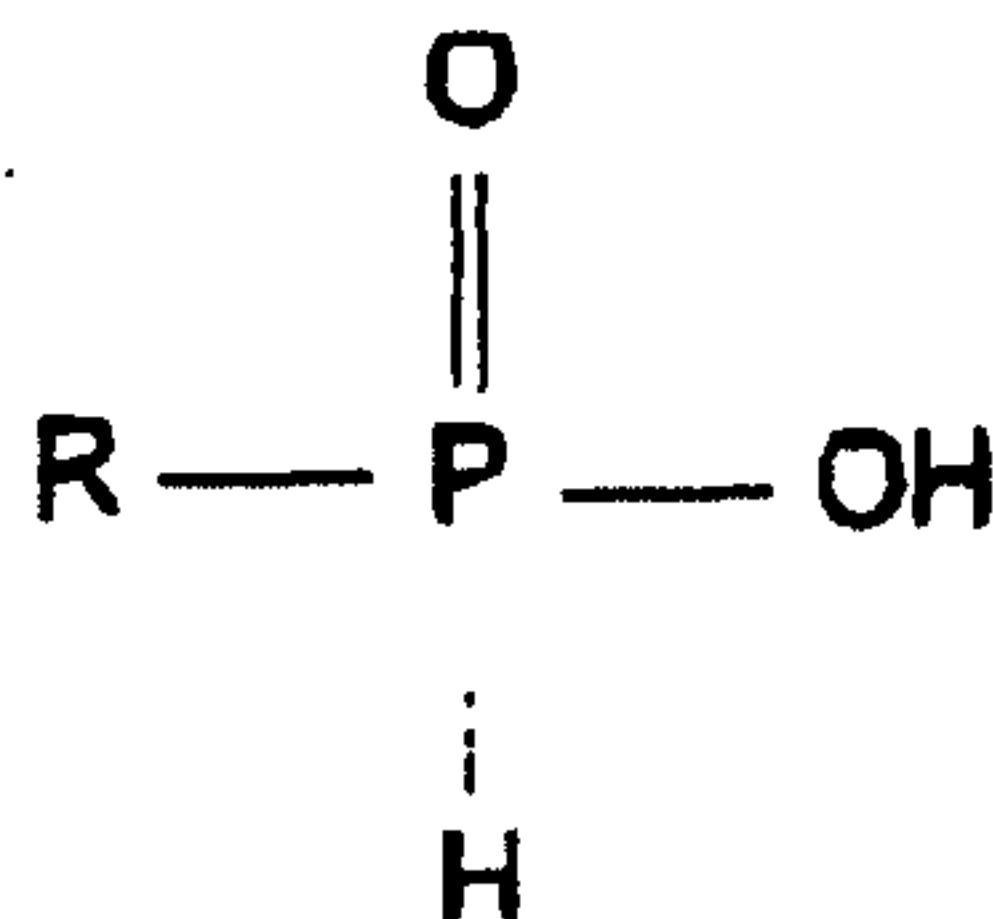
include 2'-aminoacetophenone, 3'-aminoacetophenone and 4'-aminoacetophenone. Suitable carboxy substituted aldehydes and ketones include 2-carboxybenzaldehyde, 3-carboxybenzaldehyde, 4-carboxybenzaldehyde and succinic semialdehyde.

- 5 An example of a useful derivative of an epoxy-functional material is the reaction product of a polyglycidyl ether of bisphenol A and 4-hydroxybenzaldehyde.

- 10 As discussed above, the epoxy-containing material or derivative thereof can be reacted with one or more phosphorus-containing materials to form an ester thereof, such as an organophosphate or organophosphonate. Suitable phosphorus-containing materials include phosphinic acids, phosphonic acids, phosphoric acids, phosphites, phosphonites and mixtures thereof.

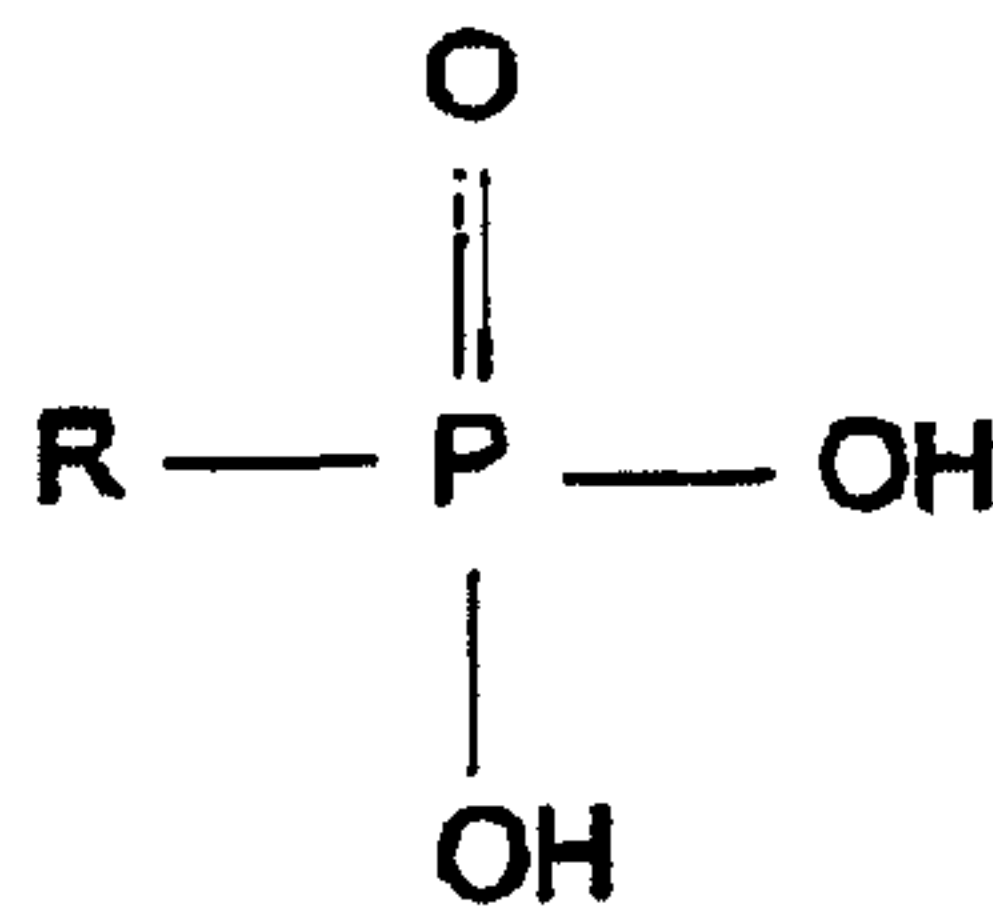
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Examples of suitable phosphinic acids include those having at least one group of the structure:



where R can be H, -C-, -(CH₂)_n- where n is an integer from 1 to 18, -O-CO-
5 (CH₂)₂-, and preferably is an aryl group such as a phenyl group. A preferred phosphinic acid is phenyl phosphinic acid (benzene phosphinic acid). Other useful phosphinic acids include glyphosate-3 and hypophosphorous acid.

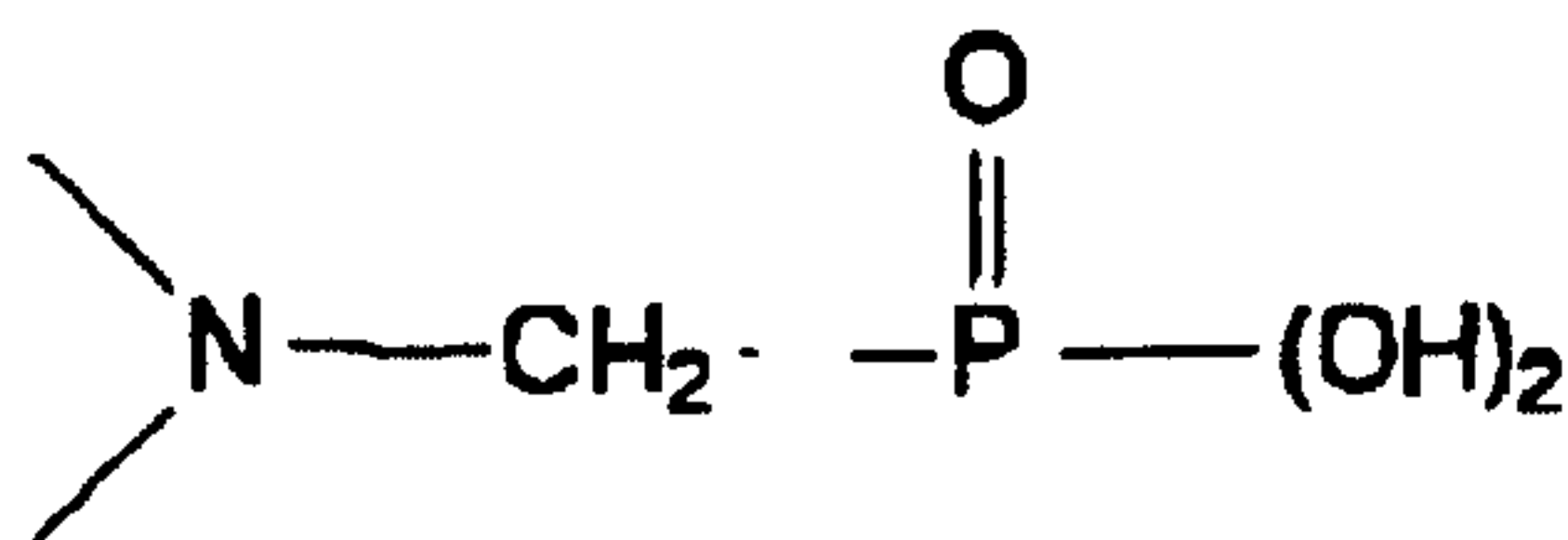
Examples of suitable phosphonic acids include those having at least one group of the structure:



10

where R can be H, -C-, -(CH₂)_n- where n is an integer from 1 to 18, -O-CO-
(CH₂)₂-, and preferably is an aryl group such as a phenyl group. A preferred phosphonic acid is phenyl phosphonic acid.

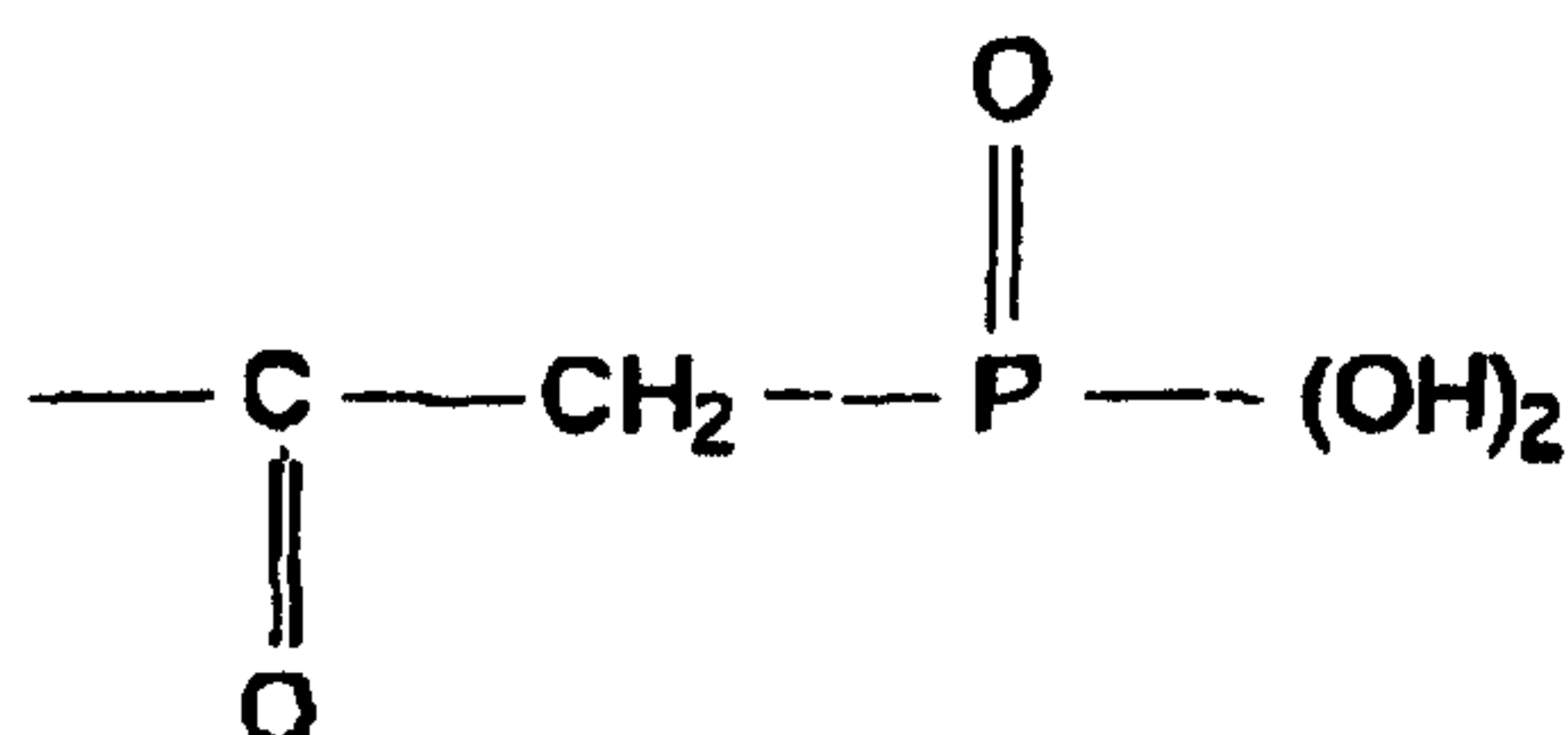
Non-limiting examples of other suitable phosphonic acids include
15 phosphorous acid, 1-hydroxyethylidene-1,1-diphosphonic acid, methylene phosphonic acids, and alpha-aminomethylene phosphonic acids containing at least one group of the structure:



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such as (2-hydroxyethyl)aminobis(methylene phosphonic) acid, isopropylaminobis(methylenephosphonic) acid and other aminomethylene phosphonic acids disclosed in U.S. Patent No. 5,034,556 at column 2, line 52 to column 3, line 43.

- 5 Other useful phosphonic acids include alpha-carboxymethylene phosphonic acids containing at least one group of the structure:



such as phosphonoacetic acid.

Other examples of useful phosphonic acids include

- 10 benzylaminobis(methylene phosphonic) acid, cocoaminobis(methylene phosphonic) acid, triethylsilylpropylamino(methylene phosphonic) acid and carboxyethyl phosphonic acid.

Suitable esters of phosphorus-containing materials include esters of any of the phosphinic acids, phosphonic acids or phosphoric acid discussed above,
 15 for example phosphoric acid esters of bisphenol A diglycidyl ether, benzylaminobis(methylenephosphonic) ester of bisphenol A diglycidyl ether, carboxyethyl phosphonic acid ester of bisphenol A diglycidyl ether, phenylglycidyl ether and butyl glycidyl ether; carboxyethyl phosphonic acid mixed ester of bisphenol A diglycidyl ether and butylglycidyl ether; triethoxyl
 20 silyl propylaminobis(methylenephosphonic) acid ester of bisphenol A diglycidyl ether and cocoaminobis(methylenephosphonic) acid ester of bisphenol A diglycidyl ether.

The epoxy-containing material or derivative thereof and phosphorus-containing material are typically reacted in an equivalent ratio of 1:0.5 to 1:10,
 25 and preferably 1:1 to 1:4. The epoxy-functional material or derivative and phosphorus-containing material can be reacted together by any method well

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known to those skilled in the art, such as a reverse phosphatization reaction in which the epoxy-containing material is added to the phosphorus-containing material.

Typically, the reaction product of the epoxy-functional material or derivative and phosphorus-containing material has a number average molecular weight of up to 10,000, and preferably 500 to 1000, as measured by gel permeation chromatography using polystyrene as a standard.

In an alternative embodiment, the pretreatment coating comprises one or more esters of a phosphorus-containing material, for example such as are discussed above. Other suitable esters include the reaction product of phosphorus pentoxide as P_4O_{10} and an alcohol in a 1:6 molar ratio of oxide to alcohol to produce a mixture of mono- and diphosphate esters, such as is disclosed in the 18 Encyclopedia of Chemical Technology, (4th Ed. 1996) at page 772. Examples of suitable alcohols include aliphatic alcohols such as ethylene glycol, phenols such as bisphenol A, and cycloaliphatic alcohols.

In an alternative preferred embodiment, the reaction product can be formed from one or more epoxy-containing materials or derivatives, such as are discussed above, and one or more amine-containing materials selected from primary amines, secondary amines, tertiary amines and mixtures thereof. Non-limiting examples of suitable primary amines include n-butyl amine and fatty amines such as ARMEEN 18D which is commercially available from Akzo Nobel. Suitable secondary amines include diisopropanolamine, diethanolamine and di-butyl amine. An example of a useful tertiary amine is ARMEEN DM18D dimethyl C18 tertiary amine.

Preferably, the amine-containing material comprises at least one alkanolamine or a mixture of different alkanolamines. Primary or secondary alkanolamines are preferred, however tertiary alkanolamines can be used. Preferred alkanolamines include alkanol groups containing less than 20 carbon atoms, and more preferably less than 10 carbon atoms. Non-limiting examples

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of suitable alkanolamines include methylethanolamine, ethylethanolamine, diethanolamine (preferred), methylisopropanolamine, monoethanolamine and diisopropanolamine. Preferred tertiary alkanolamines contain two methyl groups, such as dimethylethanolamine.

5 The epoxy-functional material or derivative and amine-containing material are preferably reacted in an equivalent ratio ranging from 5:1 to 0.25:1, and more preferably 2:1 to 0.5:1. The epoxy-functional material or derivative and amine-containing material can be reacted together by any method well known to those skilled in the art of polymer synthesis, such as
10 solution or bulk polymerization techniques. For example, an alkanolamine can be added to an epoxy-functional material and diluent, mixed at a controlled rate and the mixture heated at a controlled temperature under a nitrogen blanket or other procedure well known to those skilled in the art for reducing the presence of oxygen during the reaction. Suitable diluents for reducing the viscosity of
15 the mixture during the reaction include alcohols containing up to 8 carbon atoms, such as ethanol or isopropanol; and glycol ethers such as the monoalkyl ethers of ethylene glycol, diethylene glycol or propylene glycol.

If a tertiary alkanolamine is used, a quaternary ammonium compound is formed. Typically, this reaction is carried out by adding all of the raw materials
20 to the reaction vessel at the same time and heating the mixture, usually with a diluent, at a controlled temperature. Usually, an acid such as a carboxylic acid is present to ensure that the quaternary ammonium salt is formed rather than a quaternary ammonium hydroxide. Suitable carboxylic acids include lactic acid, citric acid, adipic acid and acetic acid (preferred). Quaternary ammonium salts
25 are useful because they are more easily dispersed in water and can be used to form an aqueous dispersion having a pH near the desired application range.

Generally, the reaction product of the epoxy-functional material or derivative and amine-containing material has a number average molecular

weight of up to 10,000, and preferably 500 to 750, as measured by gel permeation chromatography using polystyrene as a standard.

The second pretreatment composition can include one or more film-forming materials and/or crosslinking materials such as are discussed in detail
5 above for the first pretreatment composition in similar amounts.

In another alternative embodiment, the reaction product can be formed from one or more epoxy-containing materials or derivatives, such as are discussed above, and one or more sulfur-containing materials such as aliphatic or aromatic mercaptans, sulfonates, sulfones, sulfoniums, sulfides, sulfoxides
10 and mixtures thereof.

A treating solution of one or more of any of the reaction products discussed above can be prepared by mixing the reaction product(s) with a diluent, such as water, preferably at a temperature of 10°C to 70°C, and more preferably 15°C to 25°C. Preferably, the reaction product is soluble or
15 dispersible in water diluent to the extent of at least 0.03 grams per 100 grams of water at a temperature of 25°C. The reaction product generally comprises 0.05 to 10 weight percent of the treating solution on a total weight basis.

Useful diluents include water or mixtures of water and cosolvents. Suitable cosolvents include alcohols having up to 8 carbon atoms, such as
20 ethanol and isopropanol; and alkyl ethers of glycols, such as 1-methoxy-2-propanol, monoalkyl ethers of ethylene glycol, diethylene glycol and propylene glycol and dialkyl ethers of ethylene glycol or ethylene glycol formal. Preferably, the diluent includes a propylene glycol monomethyl ether such as DOWANOL^{*} PM, dipropylene glycol monomethyl ether DOWANOL^{*} DPM, which
25 are commercially available from Dow Chemical Company or MAZON^{*} 1651 butyl carbitol formal which is commercially available from BASF Corp. Other useful diluents include bases such as amines which can partially or completely neutralize the organophosphate or organophosphonate to enhance the solubility of the compound. Non-limiting examples of suitable amines include

* Trade-mark

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secondary amines, such as diisopropanolamine (preferred), and tertiary amines such as triethylamine, dimethylethanolamine and 2-amino-2-methyl-1-propanol. Non-aqueous diluents are typically present in amount ranging from 0.1 to 5 weight percent on a basis of total weight of the treating solution. Water
5 can be present in amount ranging from 50 to 99 weight percent on a basis of total weight of the treating solution.

Typically, water-soluble or water-dispersible acids and/or bases are used to adjust the pH of the treating solution to 2 to 9, and preferably 3 to 5. Suitable acids include mineral acids, such as hydrofluoric acid, fluoroboric acid,
10 phosphoric acid, sulfamic acid and nitric acid; organic acids, such as lactic acid, acetic acid, hydroxyacetic acid, citric acid; and mixtures thereof. Suitable bases include inorganic bases, such as sodium hydroxide and potassium hydroxide; nitrogen-containing compounds such as ammonia, triethylamine, methanolamine, diisopropanolamine; and mixtures thereof.

15 Optionally, the second pretreatment composition further comprises a fluorine-containing material as a source of fluoride ions. Suitable fluorine-containing materials include hydrofluoric acid, fluorosillicic acid, fluoroboric acid, sodium hydrogen fluoride, potassium hydrogen fluoride, ammonium hydrogen fluoride and mixtures thereof. Preferably, the concentration of fluorine-
20 containing material in the pretreatment coating ranges from 100 to 5200 parts per million (ppm) and more preferably 300 to 3500 ppm. Generally, the weight ratio of reaction product to fluoride ions ranges from 10:1 to 55:1.

The fluorine-containing material can be applied to the metal substrate prior to application of the second pretreatment composition or included in the
25 second pretreatment composition itself. If applied prior to application of the treating solution, the pH of an aqueous solution including the fluorine-containing material generally ranges from 2.4 to 4.0 and can be adjusted by adding sodium hydroxide.

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Optionally, the second pretreatment composition can further comprise one or more transition element-containing materials such as are discussed above. Generally, the transition element-containing material is included in the treating solution in an amount to provide a concentration of up to 10,000 ppm, and preferably 500 to 2000 ppm, based upon total weight of the treating solution.

The treating solution can further comprise surfactants that function as aids to improve wetting of the substrate. Generally, the surfactant materials are present in an amount of less than 2 weight percent on a basis of total weight of the treating solution.

Preferably, the second pretreatment composition is essentially free of chromium-containing materials, i.e., contains less than 2 weight percent of chromium-containing materials (expressed as CrO_3), and more preferably less than 0.05 weight percent of chromium-containing materials. Examples of such chromium-containing materials include chromic acid, chromium trioxide, chromic acid anhydride, and chromate and dichromate salts of ammonium, sodium, potassium, calcium, barium, zinc and strontium. Most preferably, the treating solution is free of chromium-containing materials.

In a preferred embodiment, the reaction product of an epoxy-functional material and a phosphorus-containing material is formed from EPON® 880 (828 LC) epoxy-functional resin and phenylphosphonic acid in an equivalent ratio of 1:1 to 1:2. The reaction product is present in the treating solution in an amount of 0.1 weight percent on a basis of total weight of the treating solution. The preferred treating solution also includes diisopropanolamine, solvent and deionized water.

In an alternative preferred embodiment, the reaction product of an epoxy functional material and phosphorus-containing material is formed from the reaction product of (a) EPON® 880 (828 LC) epoxy-functional resin and 4-hydroxybenzaldehyde in an equivalent ratio of 1:1 and (b) phenylphosphonic

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acid in an equivalent ratio of 1:1. The reaction product is present in the treating solution in an amount of 0.1 weight percent on a basis of total weight of the treating solution. The preferred treating solution also includes diisopropanolamine, solvent and deionized water.

5 In an alternative embodiment, the components of the first and second pretreatment compositions can be present in a single pretreatment composition.

The treating solution is applied to the surface of the metal substrate by any conventional application technique, such as spraying, immersion or roll
10 coating in a batch or continuous process. The temperature of the treating solution at application is typically 10°C to 85°C, and preferably 15°C to 40°C. The pH of the preferred treating solution at application generally ranges from 2.0 to 9.0, and is preferably 3 to 5.

The film coverage of the residue of the pretreatment coating generally
15 ranges from 0.1 to 1000 milligrams per square meter (mg/m²), and is preferably 1 to 400 mg/m².

Optionally, a weldable coating can be deposited upon at least a portion of the pretreatment coating formed from the first and second pretreatment compositions. The weldable coating is formed from a weldable composition
20 comprising one or more electroconductive pigments which provide electroconductivity to the weldable coating and one or more binders which adhere the electroconductive pigment to the pretreatment coating. The overall thickness of the pretreatment coating over which the weldable coating is applied can vary, but is generally less than 1 micrometer, preferably ranges
25 from 1 to 500 nanometers, and more preferably is 10 to 300 nanometers.

Non-limiting examples of suitable electroconductive pigments include zinc (preferred), aluminum, iron, graphite, iron phosphide, nickel, tungsten and mixtures thereof. Preferred zinc particles are commercially available from ZINCOLI^{*} GmbH as ZINCOLI^{*} S 620 or 520. The average particle size

* Trade-mark

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(equivalent spherical diameter) of the electroconductive pigment particles generally is less than 10 micrometers, preferably ranges from 1 to 5 micrometers, and more preferably 3 micrometers.

Since the metal substrates are to be subsequently welded, the weldable
5 coating must comprise a substantial amount of electroconductive pigment, generally greater than 10 volume percent and preferably 30 to 60 volume percent on a basis of total volume of electroconductive pigment and binder.

The binder is present to secure the electroconductive pigment to the
pretreatment coating. Preferably, the binder forms a generally continuous film
10 when applied to the surface of the pretreatment coating. Generally, the amount of binder can range from 5 to 50 weight percent of the weldable coating on a total solids basis, preferably 10 to 30 weight percent and more preferably 10 to 20 weight percent.

The binder can comprise oligomeric binders, polymeric binders and
15 mixtures thereof. The binder is preferably a resinous polymeric binder material selected from thermosetting binders, thermoplastic binders or mixtures thereof. Non-limiting examples of suitable thermosetting materials include polyesters, epoxy-containing materials such as are discussed above, phenolics, polyurethanes, and mixtures thereof, in combination with crosslinkers such as
20 aminoplasts or isocyanates which are discussed below. Non-limiting examples of suitable thermoplastic binders include high molecular weight epoxy resins, defunctionalized epoxy resins, vinyl polymers, polyesters, polyolefins, polyamides, polyurethanes, acrylic polymers and mixtures thereof. Another useful binder material is a phenoxy polyether polyol.

25 Particularly preferred binder materials are polyglycidyl ethers of polyhydric phenols, such as those discussed above, having a weight average molecular weight of at least 2000 and preferably ranging from 5000 to 100,000. These materials can be epoxy functional or defunctionalized by reacting the epoxy groups with phenolic materials. Such binders can have

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epoxy equivalent weights of 2000 to one million. Non-limiting examples of useful epoxy resins are commercially available from Shell Chemical Company as EPON® epoxy resins. Preferred EPON® epoxy resins include EPON® 1009, which has an epoxy equivalent weight of 2300-3800. Useful epoxy
5 defunctionalized resins include EPONOL* resin 55-BK-30 which is commercially available from Shell Oil and Chemical Company.

Suitable crosslinkers or curing agents are described in U.S. Patent No. 4,346,143 at column 5, lines 45-62 and include blocked or unblocked di- or polyisocyanates such as DESMODUR® BL 1265 toluene diisocyanate blocked
10 with caprolactam, which is commercially available from Bayer Corporation, and aminoplasts such as etherified derivatives of urea-melamine- and benzoguanamine-formaldehyde condensates which are commercially available from Cytec Industries under the trademark CYMEL® and from Solutia under the trademark RESIMENE®.

15 Preferably, the weldable coating composition comprises one or more diluents for adjusting the viscosity of the composition so that it can be applied to the metal substrate by conventional coating techniques. The diluent should be selected so as not to detrimentally affect the adhesion of the weldable coating to the pretreatment coating upon the metal substrate. Suitable diluents
20 include ketones such as cyclohexanone (preferred), acetone, methyl ethyl ketone, methyl isobutyl ketone and isophorone; esters and ethers such as 2-ethoxyethyl acetate, propylene glycol monomethyl ethers such as DOWANOL* PM, dipropylene glycol monomethyl ethers such as DOWANOL* DPM or propylene glycol methyl ether acetates such as PM ACETATE* which is
25 commercially available from Dow Chemical; and aromatic solvents such as toluene, xylene, aromatic solvent blends derived from petroleum such as SOLVESSO® 100. The amount of diluent can vary depending upon the method of coating, the binder components and the pigment-to-binder ratio, but

* Trade-mark

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generally ranges from 10 to 50 weight percent on a basis of total weight of the weldable coating.

The weldable coating can further comprise optional ingredients such as phosphorus-containing materials, including metal phosphates or the
5 organophosphates discussed in detail above; inorganic lubricants such as GLEITMO* 1000S molybdenum disulfide particles which are commercially available from Fuchs of Germany; coloring pigments such as iron oxides; flow control agents; thixotropic agents such as silica, montmorillonite clay and hydrogenated castor oil; anti-settling agents such as aluminum stearate and
10 polyethylene powder; dehydrating agents which inhibit gas formation such as silica, lime or sodium aluminum silicate; and wetting agents including salts of sulfonated castor oil derivatives such as DEHYSOL* R.

Other pigments such as carbon black, magnesium silicate (talc); zinc oxide and corrosion inhibiting pigments including calcium modified silica, zinc
15 phosphate and molybdates such as calcium molybdate, zinc molybdate, barium molybdate and strontium molybdate and mixtures thereof can be included in the weldable coating. Generally, these optional ingredients comprise less than 20 weight percent of the weldable coating on a total solids basis, and usually 5 to 15 weight percent. Preferably, the weldable coating is
20 essentially free of chromium-containing materials, i.e., comprises less than 2 weight percent of chromium-containing materials and more preferably is free of chromium-containing materials.

The preferred weldable coating includes EPON® 1009 epoxy-functional resin, zinc dust, salt of a sulfated castor oil derivative, silica, molybdenum
25 disulfide, red iron oxide, toluene diisocyanate blocked with caprolactam, melamine resin, dipropylene glycol methyl ether, propylene glycol methyl ether acetate and cyclohexanone.

The weldable coating can be applied to the surface of the pretreatment coating by any conventional method well known to those skilled in the art, such

* Trade-mark

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as dip coating, direct roll coating, reverse roll coating, curtain coating, air and airless spraying, electrostatic spraying, pressure spraying, brushing such as rotary brush coating or a combination of any of the techniques discussed above.

- 5 The thickness of the weldable coating can vary depending upon the use to which the coated metal substrate will be subjected. Generally, to achieve sufficient corrosion resistance for coil metal for automotive use, the applied weldable coating should have a film thickness of at least 1 micrometer (0.04 mils), preferably 1 to 20 micrometers and more preferably 2 to 5 micrometers.
- 10 For other substrates and other applications, thinner or thicker coatings can be used.

- After application, the weldable coating is preferably dried and/or any curable components thereof are cured to form a dried residue of the weldable coating upon the substrate. The dried residue can be formed at an elevated
- 15 temperature ranging up to 300°C peak metal temperature. Many of the binders such as those prepared from epoxy-containing materials require curing at an elevated temperature for a period of time sufficient to vaporize any diluents in the coating and to cure or set the binder. In general, baking temperatures will be dependent upon film thickness and the components of the binder. For
- 20 preferred binders prepared from epoxy-containing materials, peak metal temperatures of 150°C to 300°C are preferred.

- After the weldable coating has been dried and/or cured, the metal substrate can be stored or forwarded to other operations, such as forming, shaping, cutting and/or welding operations to form the substrate into parts such
- 25 as fenders or doors and/or to a subsequent electrocoat or topcoating operations. While the metal is being stored, transported or subjected to subsequent operations, the coatings protect the metal surface from corrosion, such as white and red rust, due to exposure to atmospheric conditions.

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Since the coated metal substrate prepared according to the present invention is electroconductive, topcoating of the coated substrate by electrodeposition is of particular interest. Compositions and methods for electrodepositing coatings are well known to those skilled in the art and a detailed discussion thereof is not believed to be necessary. Useful compositions and methods are discussed in U.S. Patent No. 5,530,043 (relating to anionic electrodeposition) and U.S. Patent Nos. 5,760,107; 5,820,987 and 4,933,056 (relating to cationic electrodeposition).

The weldable coated metal substrate optionally can be coated with a metal phosphate coating, such as zinc phosphate, which is deposited upon at least a portion of the weldable coating. Methods of application and compositions for such metal phosphate coatings are disclosed in U.S. Patent Nos. 4,941,930 and 5,238,506.

The pretreatment coating and weldable coating provide the metal substrate of the present invention with improved adhesion and flexibility and resistance to humidity, salt spray corrosion and components of subsequently applied coatings. In addition, the disposal and use problems associated with chromium can be reduced or eliminated.

The present invention will now be illustrated by the following specific, non-limiting examples. All parts and percentages are by weight unless otherwise indicated.

EXAMPLE

In accordance with the present invention, the following example shows the preparation of first and second pretreatment compositions, their application to ferrous and galvanized substrates and comparative corrosion testing results of the coated substrates.

Preparation of Panels for Corrosion Testing

Bare, or untreated cold rolled steel (CRS), two-sided electrogalvanized (EZG-60G) steel, two-sided hot-dipped galvanized (HDG-G70 70U) steel and two-sided hot-dipped GALVANNEAL* (HDA-Zn/Fe A45) test panels were purchased from ACT Laboratories, Inc. of Hillsdale, Michigan. Each panel was 10.16 centimeters (cm) (4 inches) wide, 15.24 cm (6 inches) long and 0.76 to 0.79 millimeters (mm) (0.030 to 0.031 inches) thick.

The test panels were treated according to the process described in Table 1 below.

TABLE 1

STAGE	PROCESS	DESCRIPTION
1	CLEAN	Chemkleen 163 ¹ (2% by volume) sprayed at 140° F for 1 minute
2	RINSE	Tap water, 15-30 second immersion, ambient temperature
3	TREAT	Fluorozirconic acid ² (175 ppm Zr, pH 4.5) 60 second immersion at ambient temperature
4	RINSE	Deionized water, 15-30 second immersion, ambient temperature
5	TREAT	Apply Pretreatment Solution A or B described below
6	RINSE	Deionized water, 15-30 second immersion, ambient temperature

¹Alkaline based cleaner commercially available from PPG Industries, Inc., Pittsburgh, PA

²Available as a 45% solution from Alfa Aesar, Ward Hill, MA

* Trade-mark

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As used herein, "ambient temperature" means an air temperature of 20-26°C. Each pretreatment composition was adjusted to the pH indicated below with 10% sodium hydroxide or 1% sulfamic acid, measured at ambient temperatures using a Digital Ionalyzer Model SA720, commercially available
5 from Orion Research.

Preparation and Application of Pretreatment Solutions A and B

In a preferred embodiment of the present invention, an epoxy ester of phenyl phosphonic acid was prepared in the following manner. To a 4-neck 1
10 liter round-bottom flask fitted with a reflux condenser, a mechanical stirrer and a nitrogen inlet, was charged at ambient temperature 79 grams (0.5 mole) of phenylphosphonic acid (available from Aldrich Chemical Co.) and 184.3 grams of propylene glycol monomethylether (available from Dow Chemical Co. as Dowanol PM). The mixture was heated with stirring to 51°C while maintaining
15 a nitrogen blanket.

A solution comprising 94 grams of EPON 880 epoxy-based resin (available from Shell Chemical Co.) (0.25 mole) in 219.3 grams of Dowanol PM was added to the flask at 51°C over 44 minutes. The reaction mixture was then held at 50-51°C for 196 minutes at which time the epoxy equivalent weight
20 was determined to be > 30,000 as measured by potentiometric titration with perchloric acid. To the reaction mixture was then added over 7 minutes, a solution of 33.3 grams of diisopropanol amine (0.25 mole) in 77.7 grams of Dowanol PM while the temperature increased to 53°C. The mixture was mixed thoroughly and poured into a plastic container for storage. The product mixture
25 had a solids content of 33.2% (measured @ 110°C for 1 hour) and an acid number of 59.8 (measured by potentiometric titration with methanolic KOH).

To form Pretreatment Solution A, 3.01 g of the epoxy based reaction product described above was added to a portion of deionized water with stirring. Enough deionized water was then added to bulk the solution to form

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one liter of solution. The pH of Pretreatment Solution A was then adjusted to a value of 4.5 by dropwise addition of 10% sodium hydroxide.

In an alternative embodiment of the present invention, an epoxy aldehyde modified with phenyl phosphinic acid was prepared as follows. 75.20
5 g of EPON 880 epoxy-based resin (0.4 equiv.), 48.85 g of 4-Hydroxybenzaldehyde (0.4 equiv.), 0.11 g of Ethyltriphenylphosphonium iodide were charged at room temperature into a 4-neck 1 liter round-bottom flask fitted with a reflux condenser, a mechanical stirrer and a nitrogen inlet. The reaction mixture was heated to 130°C and 2.07 g of methyl isobutyl ketone was
10 the charged into the flask. The sample was then held for 2½ hours and then 0.37 g of benzyl dimethylamine and 11.64 g of MIBK were charged to the reaction. After 3 hours, the epoxy equivalent weight was 44,000. Phenylphosphinic acid (56.84 g (0.4 equiv.)) was added to the flask and the reaction was held for an additional three hours. The reaction was cooled to
15 90°C and 53.38 g of diisopropanolamine and 484.11 g of DI H₂O were charged to the flask. The final product had a pH of 8.5 and a number average molecular weight of 666 by GPC in DMF. The product mixture had a solids content of 31.91% (110°C; 1 hr.), and an acid number of 28.6 (measured by potentiometric titration with methanolic KOH).

20 To prepare Pretreatment Solution B, 3.13 g of the epoxy based reaction product described above was added to a portion of deionized water with stirring. Enough deionized water was then added to bulk the solution to one liter. The pH of the pretreatment solution was then adjusted to a value of 4.5 by dropwise addition of 10% sodium hydroxide to form Pretreatment Solution
25 B.

Performance in Corrosion Testing

Metal panels were coated using the process described in Table 1 and evaluated for corrosion resistance. These include panels which were cleaned but not pretreated; those which were cleaned and treated with fluorozirconic acid (FZA) (Table 1, Stages 1-4 only); those in which a solution of phenyl phosphonic acid was used in Stage 5 instead of Pretreatment Solutions A or B; panels which were pretreated with FZA and either Pretreatment Solution A or B; and panels that were cleaned and phosphated with either CHEMFOS^{*} 850 or CHEMFOS^{*} 700 phosphating solutions and rinsed with CHEMSEAL^{*} 59 non-chrome containing post-rinse solution (which are commercially available from PPG Industries, Inc.).

Each panel was electrocoated with ED 6650, an electrodepositable coating commercially available from PPG Industries, Inc. Electrocoated panels were cured to achieve a metal temperature of 340°F for 20 minutes. The overall coating thickness was 23 microns (0.9 mils) on each panel.

Three different corrosion resistance tests were performed on the panels, according to the Honda Salt Dip (warm salt water immersion - 5% NaCl in deionized water solution at 55°C), GM 9540P (Cycle B) and VDA 621-415 Test Procedures (Association of German Automobile Manufacturers). Before placing panels into test, they were scribed with either a large X for testing in warm salt water immersion testing, a straight vertical line for Cycle B testing, or 2 parallel lines for VDA-621-415 testing. Upon completion of corrosion testing, corrosion by-products and delaminated paint were removed by sand blasting according to warm salt water immersion and Cycle B test specifications or by pulling off with an adhesive tape according to VDA 621-415. Results obtained from these tests are summarized in Tables 2-4 below.

* Trade-mark

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TABLE 2

SUBSTRATE TESTED	TREATMENT APPLIED ¹	CORROSION TEST PROTOCOL total paint loss from scribe (mm)		
		WARM SALT WATER ²	GM 9540 P CYCLE B ³	VDA 621-415 ⁴
Cold Rolled Steel	Clean only (Stages 1-2)	12-16	13.0	4.66
Cold Rolled Steel	FZA only (Stages 1-4)	6-8	9.8	3.83
Cold Rolled Steel	Phenyl phosphonic acid ⁵ (in Stage 5)	5-8	9.0	—
Cold Rolled Steel	FZA/Pretreatment Solution A	2-4	7.6	1.43
Cold Rolled Steel	FZA/Pretreatment Solution B	2-5	—	—
Cold Rolled Steel	CHEMFOS 850 / CHEMSEAL 59	0-1	5.0	0.90
Cold Rolled Steel	CHEMFOS 700 / CHEMSEAL 59	0-1	4.0	—
Electrogalvanized Steel EZG 60 G	Clean only (Stages 1-2)	6-11	4.33	2.53
Electrogalvanized Steel EZG 60 G	FZA only (Stages 1-4)	4-10	2.33	2.36
Electrogalvanized Steel EZG 60 G	Phenyl phosphonic acid ⁵ (in Stage 5)	4-8	3.66	—
Electrogalvanized Steel EZG 60 G	FZA/Pretreatment Solution A	2-7	3.33	2.33
Electrogalvanized Steel EZG 60 G	FZA/Pretreatment Solution B	2-8	—	—
Electrogalvanized Steel EZG 60 G	CHEMFOS 850 / CHEMSEAL 59	1-6	3.0	1.60
Electrogalvanized Steel EZG 60 G	CHEMFOS 700 / CHEMSEAL 59	0-4	3.33	—

¹ via process in Table 1 except for phosphated panels.

² 10 day immersion; average range (in mm) of paint loss from scribe for 3 panels.

³ 40 cycles completed; value is average maximum paint loss from scribe of 3 panels.

5 ⁴ German cyclic automotive test run for 10 weeks. Scribe loss, U_a , calculated by measuring the total scribe creep along one of 2 parallel scribes in seven locations and using the following equation: $U_a = [U_1 + U_2 + \dots + U_7] / 7 / 2$.

⁵ Commercially available from Acros Organics (a division of Fisher Scientific, USA); used at 0.3 g/L and pH 4.5.

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TABLE 3

SUBSTRATE TESTED	TREATMENT APPLIED	CORROSION TEST PROTOCOL		
		total paint loss from scribe (mm)		
		WARM SALT WATER	GM 9540 P CYCLE B	VDA 621-415
Hot dipped galvanized steel (HDG G70)	Clean only	2-6	2.66	1.83
Hot dipped galvanized steel (HDG G70)	FZA only	1-5	1.66	1.23
Hot dipped galvanized steel (HDG G70)	Phenyl phosphonic acid	1-4	3.0	—
Hot dipped galvanized steel (HDG G70)	FZA/Pretreatment Solution A	0-2	1.33	1.96
Hot dipped galvanized steel (HDG G70)	CHEMFOS 850 / CHEMSEAL 59	1-3	2.33	1.03
Hot dipped galvanized steel (HDG G70)	CHEMFOS 700 / CHEMSEAL 59	0-2	1.33	—

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TABLE 4

SUBSTRATE TESTED	TREATMENT APPLIED	CORROSION TEST PROTOCOL	
		total paint loss from scribe (mm)	
		WARM SALT WATER	GM 9540 P CYCLE B
GALVANNEAL (HDA-Zn/Fe A45)	Clean only	2-5	4.66
GALVANNEAL (HDA-Zn/Fe A45)	FZA only	0-4	4.00
GALVANNEAL (HDA-Zn/Fe A45)	FZA/Pretreatment Solution A	0-2	3.33
GALVANNEAL (HDA-Zn/Fe A45)	CHEMFOS 850 / CHEMSEAL 59	1-4	3.33
GALVANNEAL (HDA-Zn/Fe A45)	CHEMFOS 700 / CHEMSEAL 59	0-3	2.33

5 The data in Tables 2-4 above demonstrate that the process described in Table 1 using a pretreatment of fluorozirconic acid and Pretreatment Solution A or B according to the present invention offers a useful alternative pretreatment method to standard phosphate conversion coatings. The effectiveness of this pretreatment on a variety of substrates, particularly on cold rolled steel, an
10 inherently difficult substrate on which to inhibit corrosion, is highly desirable.

The coating compositions of the present invention provide a heavy metal-free alternative to conventional phosphating compositions; (2) a simpler operating procedure which is effective at ambient temperatures; (3) permits coating of objects comprised of mixed metallic substrates; and (4) significantly
15 reduces the amount of heavy metal sludge typically produced with conventional phosphating treatments, thus eliminating disposal concerns.

It will be appreciated by those skilled in the art that changes could be made to the exemplary embodiments described above without departing from
20 the broad inventive concept thereof as defined by the appended claims.

CLAIMS

1. A coated metal substrate comprising:
 - (a) a metal substrate;
 - (b) a first pretreatment composition deposited directly upon at least a portion of the substrate, the first pretreatment composition comprising a transition element-containing material comprising a transition element which is a Group IIIB element, a Group IVB element, a lanthanide series element or a mixture thereof;
 - (c) a second pretreatment composition comprising a reaction product of at least one epoxy-functional material or derivative thereof and at least one phosphorus-containing compound, amine-containing compound, sulfur-containing compound or a mixture thereof deposited upon at least a portion of the first pretreatment composition; and
 - (d) a lead-free electrodepositable coating composition deposited upon at least a portion of the second pretreatment composition.
2. The coated metal substrate according to claim 1, wherein the metal substrate comprises a ferrous metal.
3. The coated metal substrate according to claim 2, wherein the ferrous metal is iron, steel or alloys thereof.
4. The coated metal substrate according to claim 3, wherein the ferrous metal comprises steel is cold rolled steel, galvanized steel, electrogalvanized steel, stainless steel or a combination thereof.
5. The coated metal substrate according to claim 1, wherein the metal substrate comprises a non-ferrous metal which is aluminum, zinc, magnesium or an alloy thereof.

6. The coated metal substrate according to claim 1, wherein the Group IIIB element comprises yttrium.
7. The coated metal substrate according to claim 1, wherein the lanthanide series element is cerium, praseodymium, neodymium, samarium, europium, dysprosium or a mixture thereof.
8. The coated metal substrate according to claim 1, wherein the Group IVB element is zirconium, titanium, hafnium or a mixture thereof.
9. The coated metal substrate according to claim 8, wherein the transition element-containing material comprises zirconium and is fluorozirconic acid, potassium hexafluorozirconate, alkali salts of zirconium hexafluoride, amine salts of zirconium hexafluoride, ammonium zirconium carbonate, zirconyl nitrate, a zirconium carboxylate or a mixture thereof.
10. The coated metal substrate according to claim 8, wherein the transition element-containing material comprises titanium and is fluorotitanic acid, an alkali salt of hexafluorotitanate, an amine salt of hexafluorotitanate or a mixture thereof.
11. The coated metal substrate according to claim 1, wherein the first pretreatment composition further comprises a film-forming material.
12. The coated metal substrate according to claim 1, wherein the first pretreatment composition further comprises a carrier medium.
13. The coated metal substrate according to claim 1, wherein the first pretreatment composition is essentially free of chromium-containing materials.

14. The coated metal substrate according to claim 1, wherein the epoxy-functional material of the second pretreatment composition is the reaction product of an epihalohydrin with a polyhydric alcohol.
15. The coated metal substrate according to claim 14, wherein the epoxy-functional material is a polyglycidyl ether of bisphenol A.
16. The coated metal substrate according to claim 1, wherein the derivative of the epoxy-functional material is the reaction product of (1) an epoxy-functional compound and (2) an aldehyde or ketone.
17. The coated metal substrate according to claim 16, wherein the derivative of the epoxy-functional material is the reaction product of (1) a polyglycidyl ether of bisphenol A and (2) hydroxybenzaldehyde.
18. The coated metal substrate according to claim 1, wherein the phosphorus-containing compound of the second pretreatment composition is a phosphoric acid, a phosphinic acid, a phosphonic acid, a phosphite, a phosphonite or a mixture thereof.
19. The coated metal substrate according to claim 17, wherein the reaction product of the second pretreatment composition is an epoxy ester of phosphoric acid, an epoxy ester of phosphonic acid, an epoxy ester of phosphinic acid or a mixture thereof.
20. The coated metal substrate according to claim 1, wherein the amine-containing compound is a primary amine, a secondary amine, a tertiary amine or a mixture thereof.
21. The coated metal substrate according to claim 19, wherein the amine-containing material comprises at least one alkanolamine.

22. The coated metal substrate according to claim 1, wherein the sulfur-containing compound is a mercaptan, a sulfonate, a sulfone, a sulfonium, a sulfide, a sulfoxide or a mixture thereof.
23. The coated metal substrate according to claim 1, wherein the second pretreatment composition is essentially free of chromium-containing materials.
24. The coated metal substrate according to claim 1, wherein the second pretreatment composition further comprises at least one secondary amine which is different from the amine-containing compound from which the reaction product is formed.
25. The coated metal substrate according to claim 24, wherein the secondary amine is diisopropanol amine.
26. The coated metal substrate according to claim 1, wherein the second pretreatment composition further comprises a fluorine-containing material.
27. The coated metal substrate according to claim 26, wherein the fluorine-containing material is hydrofluoric acid, fluorosilicic acid, sodium hydrogen fluoride, potassium hydrogen fluoride, ammonium hydrogen fluoride or a mixture thereof.
28. The coated metal substrate according to claim 1, wherein the second pretreatment composition further comprises a transition element-containing material comprising a transition element which is a Group IIIB element, a Group IVB element, a lanthanide series element or a mixture thereof.
29. The coated metal substrate according to claim 1, further comprising (e) a weldable composition comprising an electroconductive pigment and a binder deposited upon at least a portion of the second pretreatment

composition.

30. The coated metal substrate according to claim 29, wherein the electroconductive pigment is zinc, aluminum, iron, graphite, iron phosphide, nickel, tungsten or a mixture thereof.

31. The coated metal substrate according to claim 29, wherein the binder comprises a thermosetting binder, which is a polyester, an epoxy-containing material, a phenolic, an aminoplast, a polyurethane or a mixture thereof.

32. The coated metal substrate according to claim 29, wherein the binder comprises a thermoplastic binder which is a vinyl polymer, a polyester, a polyolefin, a polyamide, a polyurethane, an acrylic polymer or a mixture thereof.

33. The coated metal substrate according to claim 29, wherein the weldable composition further comprises a crosslinker for crosslinking the thermosetting binder.

34. The coated metal substrate according to claim 29, further comprising a metal phosphate coating deposited upon at least a portion of the weldable composition.

35. The coated metal substrate according to claim 34, further comprising (d) an electrodeposited coating deposited upon at least a portion of the weldable composition.

36. A weldable, coated metal substrate comprising:

- (a) a metal substrate;
- (b) a first pretreatment composition comprising a transition element-containing material which comprises a transition element which is a Group IIIB

element, a Group IVB element, a lanthanide series element or a mixture thereof deposited directly upon at least a portion of the substrate;

(c) a second pretreatment composition comprising a reaction product of at least one epoxy-functional material or derivative thereof and at least one phosphorus-containing compound, amine-containing compound, sulfur-containing compound or a mixture thereof deposited upon at least a portion of the first pretreatment composition;

d) a weldable composition comprising an electroconductive pigment and a binder deposited upon at least a portion of the second pretreatment composition; and

e) a lead-free electrodepositable coating composition deposited over at least a portion of the weldable composition.

37. A coated metal substrate comprising:

(a) a metal substrate;

(b) a first pretreatment composition comprising a transition element-containing material which comprises a transition element which is a Group IIIB element, a Group IVB element, a lanthanide series element or a mixture thereof deposited directly upon at least a portion of the substrate; and

(c) a second pretreatment composition comprising an ester of a phosphorus-containing compound deposited upon at least a portion of the first pretreatment composition; and

(d) a lead-free electrodepositable coating composition deposited over at least a portion of the second pretreatment composition.

38. The coated metal substrate according to claim 37, wherein the ester of the phosphorus-containing compound is a phosphoric acid ester of an epoxy-containing material or a phosphonic acid ester of an epoxy-containing material.

39. A method for preparing a coated metal substrate, comprising the steps of:

(a) treating a surface of a metal substrate directly with a first pretreatment composition comprising a transition element-containing material which comprises a transition element which is a Group IIIB element, a Group IVB element, a lanthanide series element or a mixture thereof;

(b) applying a second pretreatment composition comprising a reaction product of at least one epoxy-functional material or derivative thereof and at least one phosphorus-containing compound, amine-containing compound, sulfur-containing compound or a mixture thereof over at least a portion of the first pretreatment composition to form a substrate having a pretreated surface; and

(c) applying a lead free electrodeposable coating composition over at least a portion of the second pretreatment composition.

40. The method according to claim 39, further comprising an additional step of applying a weldable composition to the pretreated surface of step (b) to form a weldable, coated metal substrate, the weldable composition comprising an electroconductive pigment and a binder.

41. A method for inhibiting corrosion of a metal substrate comprising:

(a) treating directly a surface of a metal substrate with a first pretreatment composition comprising a transition element-containing material which comprises a transition element which is a Group IIIB element, a Group IVB element, a lanthanide series element or a mixture thereof;

(b) applying a second pretreatment composition comprising a reaction product of at least one epoxy-functional material or derivative thereof and at least one phosphorus-containing compound, amine-containing compound, sulfur-containing compound or a mixture thereof over at least a portion of the first pretreatment composition to form a substrate having a pretreated surface;

(c) applying a weldable coating to the pretreated surface to form a corrosion-resistant coated metal substrate, the weldable coating comprising an electroconductive pigment and a binder; and

(d) applying a lead-free electrodepositable coating composition to at least a portion of the weldable coating.

42. A coated metal substrate comprising:

(a) a metal substrate;

(b) a pretreatment composition deposited directly upon at least a portion of the substrate, the pretreatment composition comprising (1) a transition element-containing material which comprises a transition element which is a Group IIIB element, a Group IVB element, a lanthanide series element or a mixture thereof; and (2) a reaction product of at least one epoxy-functional material or derivative thereof and at least one phosphorus-containing compound, amine-containing compound, sulfur-containing compound or a mixture thereof deposited upon at least a portion of the first pretreatment composition to form a pretreated substrate; and

(c) a lead-free cationic electrodepositable coating composition deposited over at least a portion of the pretreated substrate.

43. A method for preparing a coated metal substrate, comprising:

(a) the step of treating a surface of a metal substrate directly with a pretreatment composition comprising (1) a transition element-containing material which comprises a transition element which is a Group IIIB element, a Group IVB element, a lanthanide series element or a mixture thereof; and (2) a reaction product of at least one epoxy-functional material or derivative thereof and at least one phosphorus-containing compound, amine-containing compound, sulfur-containing compound or a mixture thereof over at least a portion of the first pretreatment composition to form a substrate having a pretreated surface; and

(b) the step of applying a lead-free electrodepositable coating composition to at least a portion of the pretreated surface.